

Atty. Docket No. KOV-004
Serial No: 10/616,147

Remarks

The Examiner has required restriction of the claims as follows:

1. Group I: Claims 1-40, drawn to a composition, classified in Class 106, subclass 287.1.
2. Group II: Claims 26-40, drawn to an ink composition for making a semiconductor film, classified in Class 106, subclass 285.
3. Group III: Claims 41-65, drawn to a method of making a patterned semiconductor film, by printing a composition and curing the composition, classified in Class 427, subclass 397.7.
4. Group IV: Claims 66-78, drawn to a method for forming a semiconductor film, at least by partially curing a thin film composition comprising semiconductor nanoparticles to form a semiconductor thin film lattice and coating it with a composition, classified in Class 427, subclass 397.7.
5. Group V: Claims 79-86, drawn to a method for forming a semiconductor film, by coating an at least partially cured thin film composition with an ink, classified in Class 427, subclass 397.7.
6. Group VI: Claims 87-91, drawn to a semiconductor thin film structure comprising a sintered mixture of passivated semiconductor particles in a hydrogenated and at least partially amorphous Group IV A element, classified in Class 428, subclass 403.

Applicant has elected Group III, Claims 41-65, drawn to a method of making a patterned semiconductor film, without traverse. Claims 1-40 and 66-91 are now believed to be withdrawn from consideration as being drawn to non-elected Groups.

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Conclusions

In view of the above election and remarks, Claims 41-65 are in condition for examination on the merits. Early notice to that effect is earnestly requested.

If it is deemed helpful or beneficial to the efficient prosecution of the present application, the Examiner is invited to contact Applicant's undersigned representative by telephone.

Respectfully submitted,



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